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(54) **Producing metal patterns on a substrate.**

(57) Conductive patterns may be formed on the surface of thermally inefficient substrates by depositing a uniform layer of metal thereover whose upper surface is substantially UV absorbing followed by laser ablation of the deposited metal to leave the deposited metal only in the desired metal pattern. Thermally efficient substrates (10) may be rendered thermally inefficient by the deposition of a thermally inefficient material thereon. That thermally inefficient material may be either electrically insulating or a metal. A two layer metallization comprising a first, thermally inefficient reactive metal (22) and a second UV absorbing metal (24) is preferred. When disposed on a thermally inefficient substrate, this two layer metallization ablates reactively as the two layers burn off together. This laser ablation process substantially roughens the surface of polymer dielectrics and may be used to repair open traces in printed circuit structures.



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FIG.1

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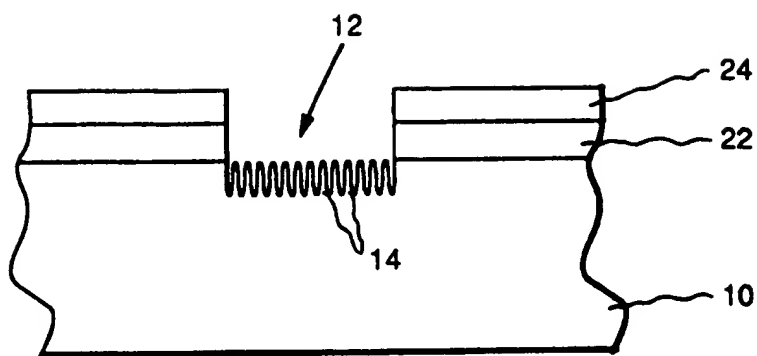


FIG.5



European Patent
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EUROPEAN SEARCH REPORT

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DOCUMENTS CONSIDERED TO BE RELEVANT			
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl.5)
A	US-A-4 826 785 (INMOS) * abstract * * column 3, line 44 - column 5, line 11 *	1	H01L21/48
A	EDN ELECTRICAL DESIGN NEWS. vol. 17, no. 13, 1 July 1972, NEWTON, MASSACHUSETTS US page 14; 'Circuits Formed on Ceramic Substrates with Laser "Machining" Process' * the whole document *	1,5,7,16	
A	US-A-4 786 358 (SEMICONDUCTOR ENERGY LABORATORY) * the whole document *	7,15,16	
A	D. BAUERLE: "Chemical Processing with LASERS", Springerverlag, 1986, ISBN 3-540-17 147-9, pp.162-170 *p169-170, "8.1 Metals"*	8-12	
A	EP-A-0 180 101 (IBM) * abstract *	4,14	
A	IBM TECHNICAL DISCLOSURE BULLETIN. vol. 8, no. 12, May 1966, NEW YORK US page 1733; H. L. CASWELL: 'Electroforming Film Patterns for Interconnections'		TECHNICAL FIELDS SEARCHED (Int. Cl.5)
			H01L
The present search report has been drawn up for all claims			
Place of search THE HAGUE		Date of completion of the search 11 MARCH 1992	Examiner PROHASKA G. A.
CATEGORY OF CITED DOCUMENTS		T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons ----- A : member of the same patent family, corresponding document	
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